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001/030

020732-97.668 (7493)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re United States Patent Application of:

Docket No.: 020732-97.668
(7493)

Applicants: **RATH, Melissa K., et al.**

Conf. No.: 4823

Application No.: 10/792.038

Art Unit: 1752

Date Filed: March 3, 2004

Examiner: LE, Hoa Van

Title: COMPOSITION AND PROCESS FOR POST-ETCH REMOVAL OF PHOTORESIST AND/OR SACRIFICIAL ANTI-REFLECTIVE MATERIAL DEPOSITED ON A SUBSTRATE

Customer No.: 24239

FACSIMILE TRANSMISSION CERTIFICATE

Attn: Examiner Hoa Van Le

Fax No. (571) 273-8300

I hereby certify that this document is being filed in the United States Patent and Trademark Office, via facsimile transmission to Mail Stop Amendment, Commissioner for Patents, PO Box 1450, Alexandria, VA 22313-1450, on October 2, 2006, to United States Patent and Trademark Office facsimile transmission number (571) 273-8300.

30
Number of Pages (including cover)

Lillian Glenn

October 2, 2006
Date

RESPONSE TO AUGUST 30, 2006 OFFICE ACTION IN UNITED STATES PATENT APPLICATION NO. 10/792,038

**Mail Stop Amendment
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450**

Sir,

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Please amend the claims, as set out in the following Section I (the Claims).

Remarks addressing the substance of the August 30, 2006 Office Action are set out in the Section II (Remarks) hereof.

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